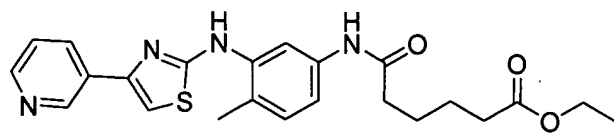
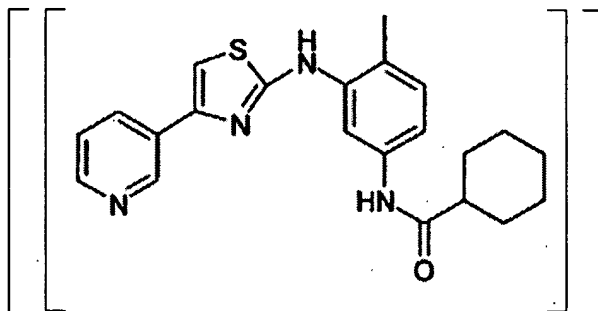


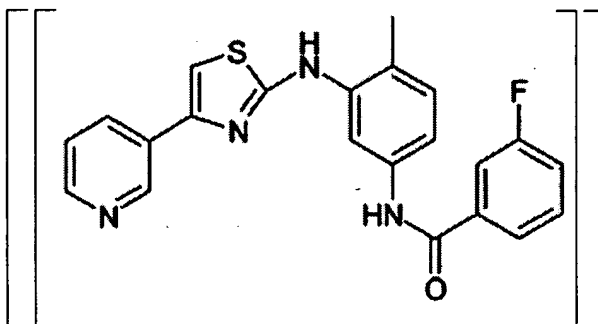
**Amendments to the Specification:**

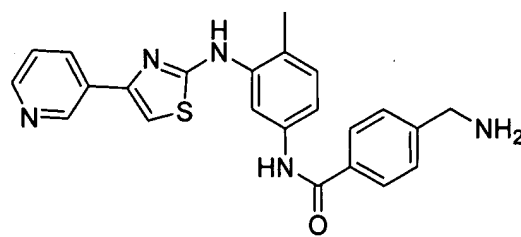
Please amend the specification as follows:

Please replace the chemical structure on page 26, between line 5 and line 10 thereof, with the replacement chemical structure as indicated below:



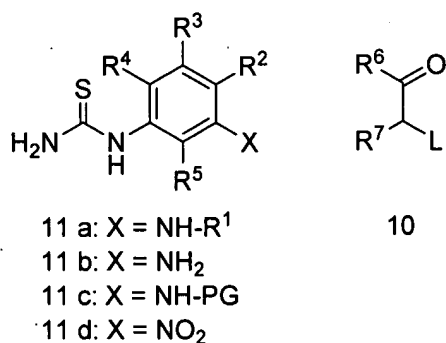
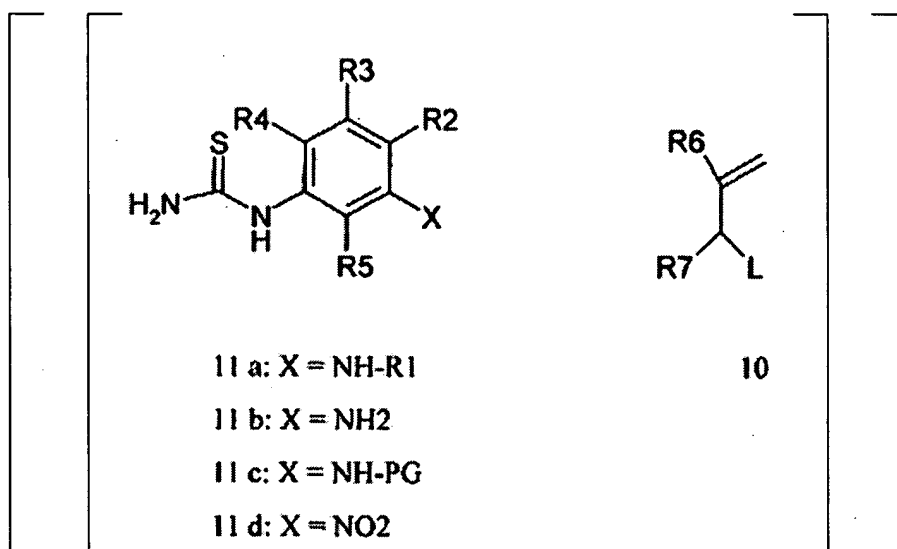
Please replace the chemical structure on page 51, at approximately line 5 thereof, with the replacement chemical structure as indicated below:





Please replace the paragraph and accompanying figure starting at page 76, line 5, and concluding on page 77, line 2, with the following replacement paragraph and figure as indicated:

In a second embodiment, the invention is directed to a process for manufacturing a compound of formula I depicted above. This entails the condensation of a substrate of general formula 10 with a thiourea of the type 11a-11d.



Substituent "L" in formula 10 is a ~~nucleofugal~~ leaving group suitable in nucleophilic substitution reactions (for example, L can be selected from chloro, bromo, iodo, toluenesulfonyloxy, methanesulfonyloxy, trifluoromethanesulfonyloxy, etc., with L being preferentially a bromo group).